

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of
Masanobu SATO et al.
Serial No.: 10/767,756
Filed: January 28, 2004

Confirmation No.: 5571
Date: March 8, 2007
Group Art Unit: 2813
Examiner: Unassigned

For: SUBSTRATE TREATMENT METHOD AND SUBSTRATE TREATMENT
APPARATUS

VIA EFS-WEB
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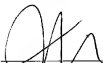
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Sir:

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Respectfully submitted,



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APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/767,756		OPGS File No. P/2699-32		
		Applicant Masanobu SATO et al.				
		Filing Date January 28, 2004		Group / Art Unit 2813		
U.S. PATENT DOCUMENTS						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-					
	US-					
	US-					
	US-					
FOREIGN PATENT DOCUMENTS						
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation
						Yes No
	1999-013348	02-1999	Korea			English language translation of corresponding Japanese Patent Publication No. 11-031673
	2000-254554	09-2000	Japan			X
	2002-224592	08-2002	Japan			X
	10-197145	07-1998	Japan			X
	2001-137747	05-2001	Japan			X
	4-322731	11-1992	Japan			X
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
	Written Opposition issued December 12, 2006 in connection with the Korean Patent Application No. 10-2004-0011748 (Patent No. 602894)					
Examiner		Date Considered				

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